Automated IC Inspection Microscope L200A

Nikon







The next generation in automated IC inspection microscopy

The Eclipse L200A has scored major advances in the standardization of inspection and safeguards against contamination. In a new design that combines motorized control with automated operation, observation conditions can be programmed for each individual objective or for each substrate to be inspected. Focus position, objective magnification, illumination control and other microscope methods are fully programmable and can be recalled instantly. This eliminates deviation in inspection results that might occur due to different settings made by multiple users.



To minimize the chance of contamination, the L200A's aperture control and other major operations are now motorized, enabling remote control for use on unattended IC production lines. Like other Eclipseseries microscopes from Nikon, the

L200A features industry-acclaimed CFI60 infinity optics.

Include an ergonomic design for comfortable viewing, a rigid, vibration resistant construction, and you have a microscope unsurpassed to meet the stringent requirements of the latest semiconductor fabs. The L200A is the next step upward in automated IC inspection microscopy.





*Active when the respective optional module is attached

Motorized, remote control minimizes the chance of contamination, while enhancing productivity

Frequently used operations such as aperture control, focusing, brightfielddarkfield changeover, nosepiece rotation, lamp intensity control, and DIC setting (option) are all motorized and can be controlled by the remote controller or a PC. In addition, there is virtually no operation that requires manual adjustment above the sample, therefore preventing particle contamination introduced from the operator.







Option keys

Cursor keys Menu kev

Enter kev

Lamp intensity Auto/ Manual changeover key Lamp intensity control knob

AF-MF changeover key* Focus fine adjustment knob* (When AF is ON)

Focus dial

Focus Coarse/Fine changeover key



Free from deviations in inspection results, due to human errors and differences in microscope settings

Optimum observation conditions including focus position, aperture, light intensity, as well as DIC prism and polarizer position can be preset objective-by-objective and recalled simply by selecting the objective. This eliminates the need to configure these settings each time the microscope is used, providing standardized observation regardless of who operates the microscope.

Easy configuration into an automated inspection system

Annigo this invege to highlighted detect

Manu Pick England on Sampley Intercontention

Programmed settings

As an inspection process varies depending on substrate, layer, and even the operator, it has been necessary to readjust settings for each inspection process. The L200A's programming feature eliminates this process. You just select the settings-such as observation method, objective magnification, point to be checked, focus position, aperture, and light intensity-and save them by attaching appropriate file names. All you need do to begin your inspection is just to specify the file name.



100

Nikon

DART software (option)

Accept Reart Nocal Disertion Pick Disgn Stop Federer Lut End

espelater (2) Wall For Fiscal espectador : Flavory

DART Software is an integrated software package that can fully automate the inspection process.

DART combined with an NWL860 wafer loader, ISS200 Motorized Stage and a L200A Auto Focus offers a complete automated wafer inspection station. DART software modules allow further upgrades with options such as image archiving,

defect review, post probe review and online

Test Har whole the

Ealar. IT

communications.

Nether Out



Top-notch basic performance facilitates inspections

Accessories to enhance performance

CF60 Optical System



Nikon's renowned CFI60 optics are the fusion of CF design and infinity optics. These new optics feature longer working distances and high N.A.'s. They also produce brighter images with more contrast and reduced flare.

High-contrast darkfield images

A new illumination system produces a Signal to Background (S/B) ratio that is nearly three times greater than former models. This improves sensitivity during darkfield



observations, enabling the detection of minute scratches and surface irregularities within the sample, and provides exceptionally high contrast.

Safeguards against contamination

The body of this microscope is finished with electrostatic discharge (ESD) coatings to prevent foreign particles from adhering to it. Furthermore, the motorized nosepiece uses a shielded center-motor that traps foreign particles inside, preventing them from falling onto the sample.

SEMI S2-93A, S8-95 compliant design



A tilting trinocular eyepiece tube with a lower eyepoint designed to be closer to the operator allows you to sit in a more natural erect position. Microscope controls located comfortably up-front in the microscope base minimize hand movement, allowing you to concentrate on the inspection process.

Centerable motorized nosepiece

The sextuple motorized nosepiece not only has the same encoded positioning system offered on the Eclipse L200, but it also offers three adjustable objective positions that improve par-centricity even more.



Vibration-isolation design

Thanks to Computer-Aided Engineering, the L200A is three times less susceptible to floor vibrations when compared with conventional models in this class. This reduces the chance of unwanted blur or image shifts even during highmagnification observations.



CF

	LU	/L	Plan	series	objectives	
--	----	----	------	--------	------------	--

Туре	Magniii-	IN.A.	W.D.
	cation		(mm)
CFI L Plan Epi*	2.5X	0.075	8.80
CFI LU Plan Epi*	5X	0.15	23.50
	10X	0.30	17.30
	20X	0.45	4.50
	50X	0.80	1.00
	100X	0.90	1.00
CFI LU Plan Epi ELWD*	20X	0.40	13.00
	50X	0.55	10.10
	100X	0.80	3.50
CFI L Plan Epi SLWD*	20X	0.35	24.00
	50X	0.45	17.00
	100X	0.70	6.50
CFI LU Plan Apo Epi*	150X	0.95	0.30
CFI L Plan Apo Epi WI*	150X	1.25	0.25
CFI LU Plan BD	5X	0.15	18.00
	10X	0.30	15.00
	20X	0.45	4.50
	50X	0.80	1.00
	100X	0.90	1.00
CFI LU Plan BD ELWD	20X	0.40	13.00
	50X	0.55	9.80
	100X	0.80	3.50
CFI LU Plan Apo BD	150X	0.90	0.42
	1 1 .	. 1	4.4

lamphouse •75W xenon lamphouse

•150W metal halide

Stages and wafer holders

•8x8 Stage •8-inch (200mm) wafer holder •6-inch (150mm) wafer holder •6-inch (150mm) mask holder •5-inch (125mm) mask holder •4-inch (100mm) mask holder

* A nosepiece adapter is needed to use these objectives

System Diagram



Illumination systems

•12V-100W halogen lamphouse •100W mercury lamphouse

DXM1200 digital camera

The DXM1200 Digital Camera achieves ultrahigh-quality digital images equivalent to approximately 12 million output pixels, plus has a low-noise design for clear, low-light image capture. The camera's software can be set to automatically categorize the images taken, sort them and save them, all automatically—a powerful feature when you take a large number of photomicrographs.





Specifications

Observation method	Brightfield, darkfield, DIC, simple polarizing	Stage	8x8 Stage, Cross travel: 205 x 205 Coarse/fine-movement changeov Wafer holders: 4-8 in., Mask hold	
Main body	Episcopic stand, Power supply built-in			
Focusing mechanism	Stroke: 29mm, Coarse: 12.7mm per rotation (torque adjustable, focusing stop mechanism provided), Fine: 0.1mm per rotation (in 1µm increments), Guide: 4-guide (two roller-race, torque adjustable)	Control	Front panel: Nosepiece rotation l Episcopic aperture diaphragm st intensity control knob Remote control: LCD panel, Mag changeover, Motorized Z-axis, Ep diaphragm stop buttons, Light in knob, Motorized bright/darkfield DIC adjustment knob, Option key	
Episcopic illuminator	Motorized aperture diaphragm (centerable, pinhole slider incorporated) Fixed field diaphragm (with focus target), Four			
	ø25mm filters (NCB11/ND4,16) can be mounted; Polarizer, Analyzer	Eyepieces	CFI eyepiece lens series	
Light sources	100W halogen 150W metal halide 100W mercury	Control Eyepieces Objectives Auto focus unit Automated function Communication Weight	CFI LU/L Plan series	
	75W Xenon	Auto focus unit	Optional (LED)	
Eyepiece tube	UW tilting trinocular eyepiece tube (tilt angle: 0°-	Automated function	Recipe Programming	
	30 ; erect images), F.O.V.: 25mm, Optical path changeover: 2-way (Bino: Photo 100:0/0:100)	Communication	RS-232C	
Nosepiece	Fixed-motorized sextuple universal nosepiece (centarable), Highly durable	Weight	Approx. 45kg (when 8x8 Stage an tube are used.)	

Specifications and equipment are subject to change without any notice or obligation on the part of the manufacturer. September 2002. DART software is developed by Nikon Inc.

©2000-02 NIKON CORPORATION



TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING YOUR EQUIPMENT.



er: manual, ers: 4-6 in. outtons, op buttons, Light

nification iscopic aperture tensity control changeover key,

d UW eyepiece

NIKON INSTECH CO., LTD. NIKON INSTRUMENTS EUROPE B.V. NIKON INSTRUMENTS INC.

Parale Mitsui Bldg., 8, Higashida-cho, Kawasaki-ku, Kawasaki, Kanagawa 210-0005, Japan phone: +81-44-223-2175 fax: +81-44-223-2182 http://www.ave.nikon.co.jp/inst/

NIKON SINGAPORE PTE LTD SINGAPORE phone: +65-5593618 fax: +65-5593668 NIKON MALAYSIA SDN. BHD.

MALAYSIA phone: +60-3-78763887 fax: +60-3-78763387

P.O. Box 222, 1170 AE Badhoevedorp, The Netherlands phone: +31-20-44-96-222 fax: +31-20-44-96-298 http://www.nikon-instruments.com/ **NIKON FRANCE S.A.**

FRANCE phone: +33-1-45-16-45-16 fax: +33-1-45-16-00-33

NIKON GMBH GERMANY phone: +49-211-9414-0 fax: +49-211-9414-322 **NIKON INSTRUMENTS S.p.A.**

ITALY phone: + 39-55-3009601 fax: + 39-55-300993

NIKON AG

SWITZERLAND phone: +41-1-913-62 00 fax: +41-1-910-37 44 NIKON UK LTD. UNITED KINGDOM phone: +44-20-8541-4440 fax: +44-20-8541-4584

1300 Walt Whitman Road, Melville, N.Y. 11747-3064, U.S.A. phone: +1-631-547-8500; +1-800-52-NIKON (within the U.S.A.only) fax: +1-631-547-0306 http://www.nikonusa.com/

NIKON CANADA INC.

CANADA phone: +1-905-625-9910 fax: +1-905-625-0103

Code No. 2CE-KWLH-1

This brochure is printed on recycled paper made from 40% used material.

Free Manuals Download Website <u>http://myh66.com</u> <u>http://usermanuals.us</u> <u>http://www.somanuals.com</u> <u>http://www.4manuals.cc</u> <u>http://www.4manuals.cc</u> <u>http://www.4manuals.cc</u> <u>http://www.4manuals.com</u> <u>http://www.404manual.com</u> <u>http://www.luxmanual.com</u> <u>http://aubethermostatmanual.com</u> Golf course search by state

http://golfingnear.com Email search by domain

http://emailbydomain.com Auto manuals search

http://auto.somanuals.com TV manuals search

http://tv.somanuals.com